

Nonvolatile programmable silicon photonics based on phase-change materials



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We demonstrate nonvolatile electrically tunable silicon photonic switches based on PIN diode and graphene heater.

Emerging PCMs Sb_2Se_3 and Sb_2S_3 are further explored for ultra low-loss operation from the visible to near IR.

Reconfigurable silicon photonics

- ✓ Thermo-optic / electro-optic effects
- ✓ Challenges: small tuning, volatile → large footprint, energy consumption

● Phase-change materials (PCMs)

- ✓ High optical contrast ($\Delta n > 1$) between amorphous and crystalline states
- ✓ Nonvolatile ~10 years
- ✓ Fast (ns), low-energy (fJ/bit), reversible switching with high cyclability (10^{15}).
- ✓ Excellent scalability

Highlights

> A low-loss, compact, nonvolatile, programmable Si photonic platform.

> high endurance with cyclability >1000

> Ultra low switching energy down to 8.7 aJ/nm^3

> A low-loss phase shifter enabled by Sb_2Se_3

> Applications in microwave photonics, data centers, neural networks, quantum information processing ...

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Publication:

Zheng, J., Z. Fang, et al. *Adv. Mater.* (2020).

Xu, P., J. Zheng, et al. *ACS Photon.* (2019)

Fang, Z., J. Zheng, et al. *Adv. Opt. Mater.* (2021).

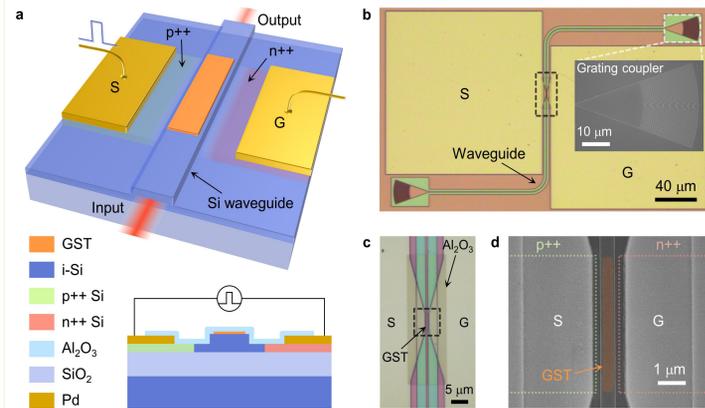
Fang, Z., R. Chen, et al. *Under Review* (2021).

Chen, R., Z. Fang, et al. *arXiv* (2022).

Photonic Switches based on PIN microheater

● Design and fabrication

- ✓ 120 nm partially etched WGs
- ✓ Heavily doped (10^{20} cm^{-3}) PIN junctions, 200 nm away from ribs
- ✓ Near-zero extra loss is achieved after doping
- ✓ Encapsulated by 40 nm ALD Al_2O_3

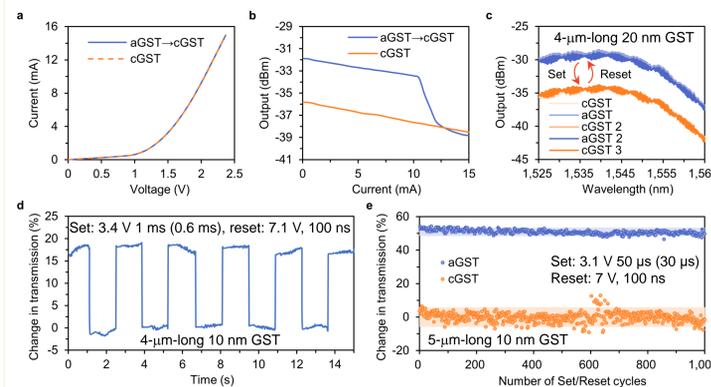


● Performance characterization

- ✓ Rectification IV curve (GST not in the circuit)
- ✓ **Reversibly** switched with a high extinction ratio ~5 dB over a broad bandwidth
- ✓ **High cyclability**: >500 cycles

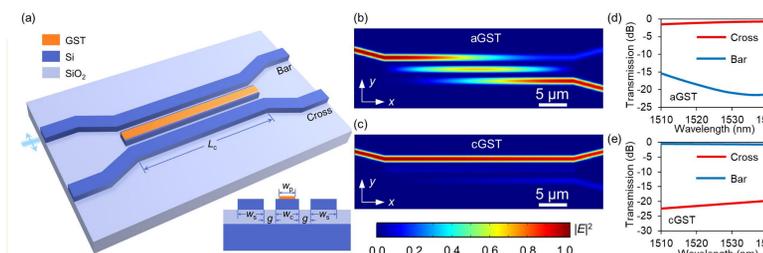
● Operating principle

- ✓ A 5- μm -long switching unit with 10 nm GST
- ✓ Reset: 7V (~110 mW), 100 ns
- ✓ Set: 3.5 V (~10 mW), 50 μs (30 μs falling edge)



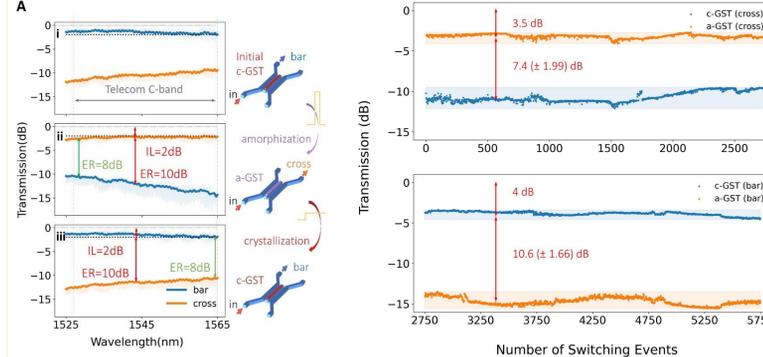
● Design of broadband 2x2 switches:

- ✓ Middle waveguide used to circumvent the high crystalline GST loss



● Performance characterization

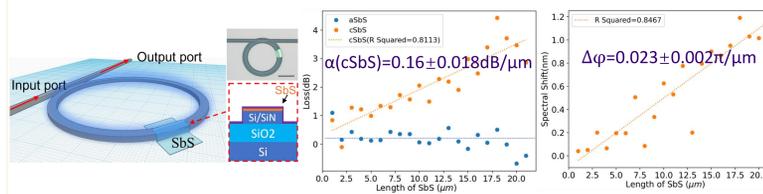
- ✓ **Reversibly** switched with a high extinction ratio >10 dB over the entire telecom C-band
- ✓ **High cyclability**: >2,800 cycles
- ✓ Small insertion loss <2dB



Low-loss Sb_2S_3 on silicon microrings

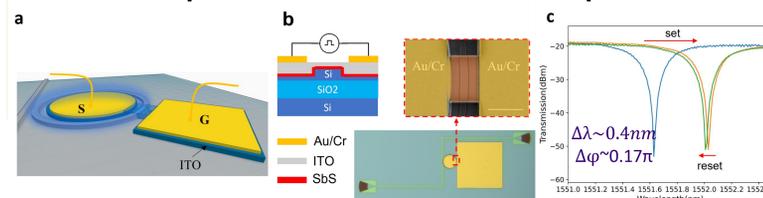
● Wide bandgap PCM Sb_2S_3 (SbS)

- ✓ Broadband transparency from 610nm to near IR
- ✓ **Zero** loss in amorphous state and 0.16dB/ μm in crystalline state near 1550nm, almost **50 times smaller** than that of cGST



● Electrical actuation of 8 μm Sb_2S_3 by an integrated ITO heater

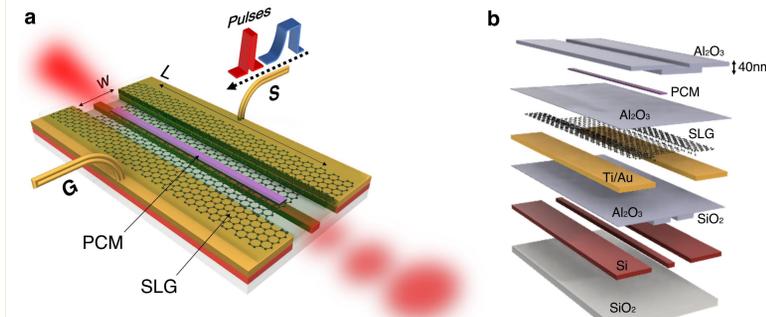
- ✓ No observable resonance broadening
- ✓ 0.48dB insertion loss
- ✓ **0.17π phase modulation desirable for phase shifters!**



Graphene heater for ultra-low energy switching

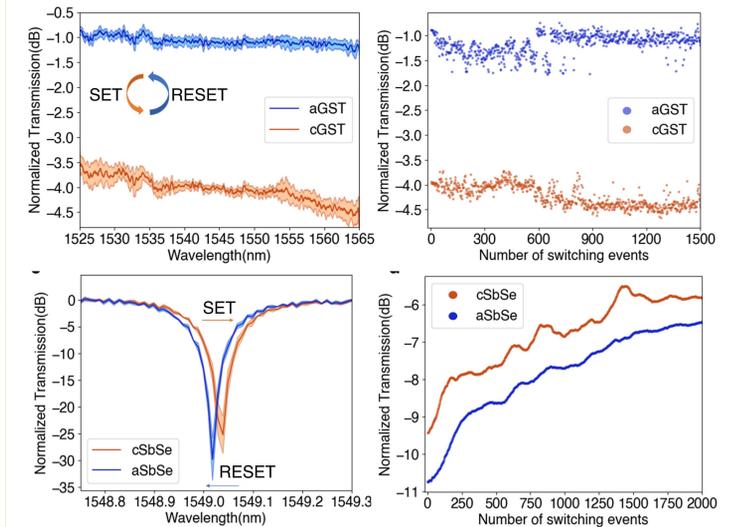
● Design and fabrication

- ✓ Planarized SOI waveguides
- ✓ ALD Al_2O_3 spacer between graphene and PCM
- ✓ Encapsulated by 40 nm ALD Al_2O_3
- ✓ **Near Zero** loss induced by the graphene ($\sim 0.047 \text{ dB}/\mu\text{m}$)
- ✓ Compatible with dielectric platforms e.g., Si_3N_4



● Performance characterization

- ✓ Broadband switching based on GST and phase shifter based on Sb_2Se_3
- ✓ **Ultra-low** switching energy density per bit $\sim 8.7 \text{ aJ/nm}^3$
- ✓ Energy efficiency approaching fundamental limit 1.2 aJ/nm^3
- ✓ **High cyclability**: >1,000 cycles



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